A patent has been granted (Patent No. 313151, dated 24.05.2019) by the Patent Office, Government of India, New Delhi to the Forest Research Institute on the invention entitled: A process for the isolation of Ursolic acid from *Eucalyptus hybrid Leaves* (Patent Application No. : 361/DEL/2009). The Inventors of the Patent were Dr. Praveen Onial, CTO and Dr. Rameshwar Dayal Ex. Head Chemistry and Bioprospecting Division, Forest Research Institute, Dehradun.
No. 361/DEL/2009

Dated the 24/03/2019

To:
Address of Service: MONA SAINIL S. DAVAR & CO., 5/1 (1ST FLOOR) PATENT & TRADEMARKS ATTORNEY, KALKAJI EXTENSION, NEW DELHI-110196, INDIA.
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Sub: Intimation of the grant and record of patent under section 43 of the Act in respect of patent application no. 361/DEL/2009

M Pulli Madam,

This is to inform you that following the examination of above mentioned patent application under section 12 and 13 of The Patents Act, 1970 and rules made thereunder [and hearing held on 26/06/2018] a patent is hereby granted and recorded in the Register of Patents on the 24/05/2019. The Patent Certificate is enclosed herewith.

Patent No.: 313151
Name Of Applicant: THE DIRECTOR, FOREST RESEARCH INSTITUTE
Date of Patent: 25/02/2009
Priority Date: 25/02/2009
Examined date: 25/11/2009
Title: "A PROCESS FOR THE ISOLATION OF URSOLIC ACID FROM EUCALYPTUS HYBRID (LEAVES)"

The grant of above mentioned patent will be published in the Official Journal of the patent Office under section 43 of the Act.

Dr. Sunita Ram
Controller of Patents

Notes:
1. The fee for renewal of the patent is Rs. 500 and is to be paid along with the application for renewal of the patent on the prescribed date.
2. No hard copy of the Patent Certificate shall be issued separately by the Office.
It is hereby certified that a patent has been granted to the patentee for an invention entitled "A PROCESS FOR THE ISOLATION OF URSOLIC ACID FROM EUCALYPTUS HYBRID (LEAVES)" as disclosed in the above mentioned application for the term of 20 years from the 25th day of February 2009 in accordance with the provisions of the Patents Act, 1970.